### Monday Afternoon, December 8, 2014

### Thin Films

Room: Lehua - Session TF+NM-MoE

### Nanostructures, Graphene, and Magnetism

**Moderator:** Stephen Muhl, Instituto de Investigaciones en Materiales, Universidad Nacional Autónoma de México

#### 5:40pm TF+NM-MoE1 Low-Dimensional Electronic System on Metal-Adsorbed Germanium Surfaces, Kan Nakatsuji, Tokyo Institute of Technology, Japan INVITED

The electronic properties of metallic nano-materials attract much interests not only because of their potential application to novel electronic devices but fundamental low-dimensional physics point of view. One of the ways to fabricate nano-materials is to deposit small amount of metal atoms on crystalline semiconductor surfaces. In the present study, we have investigated atomic and electronic structures of gold adsorbed Ge(001) and Ge(111) surfaces which exhibit one- and two-dimensional atomic structure, respectively, by scanning tunneling microscopy (STM), angle-resolved photoelectron spectroscopy (ARPES) and density functional calculations.

The Au-adsorbed Ge(001) surface has periodic arrangement of onedimensional (1D) chain structure and a metallic surface state. This metallic state has been reported to be strictly 1D showing Tomonaga-Luttinger liquid (TLL) behavior[1]. In the present study, its band shape was precisely investigated using a single-domain surface prepared on a vicinal substrate. Our ARPES results clearly revealed that the band has anisotropic twodimensional (2D) shape in contrast to the previous report. The band dispersion is steeper in the direction perpendicular to the chain contrary to the intuitive expectation from 1D structure[2]. Our STM study revealed that the top of the 1D chain shows 8 times periodicity on average along the chain with a lot of defects[3]. This rather high density of defects may cause the reduction of density of states at the Fermi level which was previously interpreted as a TLL behavior.

The Au-adsorbed Ge(111) surface exhibits  $\sqrt{3} \times \sqrt{3}$  periodicity. Two metallic surface states, S<sub>1</sub> and S<sub>2</sub>, were observed around  $\Gamma$ , which is consistent with the calculated band structure of the CHCT model. 2D electronic system is confirmed by a rounded hexagonal Fermi surface of S<sub>1</sub> ban[4] which has contributions from surface Au and Ge atoms. S<sub>2</sub> is originated only from the Ge atoms. These surface bands split into spin-polarized bands owing to the strong spin-orbit interaction[5]. The modification of the electron filling of the S<sub>1</sub> band by additional Au atoms will be also discussed[6].

The author thanks Y. Motomura, R. Niikura and Prof. F. Komori in Institute for Solid State Physics, University of Tokyo for their close collaboration, and Y. Oda and Prof. A. Ishii in Tottori University for their collaboration in theoretical part of this work.

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- [2] K. Nakatsuji et al., PRB 84 (2011) 115411.
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- [4] K. Nakatsuji et al., PRB 80 (2009) 081406®.
- [5] K. Nakatsuji et al., PRB 84 (2011) 035436.
- [6] K. Nakatsuji et al., JPCM 25 (2013) 045007.

6:20pm TF+NM-MoE3 Effective Mass of a Two-Dimensional  $\sqrt{3x}\sqrt{3}$  Ga Single Atomic Layer on Si(111), Michael Schnedler, Forschungszentrum Jülich GmbH, Germany, Y. Jiang, Peking University, China, K.H. Wu, Institute of Physics, Chinese Academy of Sciences, China, E.G. Wang, Peking University, China, R.E. Dunin-Borkowski, P. Ebert, Forschungszentrum Jülich GmbH, Germany

The transport of charge carriers in semiconductor nanostructures is particularly important for nanoscale devices. In a semi classical approach, the transport of charge carriers is to a large degree governed by the effective masses of electrons and holes, which are reasonably well known for most bulk materials. However, with ongoing miniaturization of semiconductor devices and the trend towards the use of nanostructures, the increasing surface to volume ratio reduces the relative fraction of bulk material. Hence, transport in semiconductor nanostructures is to a large degree determined by surface and/or interface effects, where little is known about the effective masses.

The effective masses of surface states can be derived from angle-resolved photoemission spectroscopy (ARPES), but it is hardly applicable on *individual* nanostructures. In contrast scanning tunneling spectroscopy (STS) is ideally suited for probing the local density of states of an individual nanostructure, but it is a very difficult task to quantitatively

measure the involved k vectors and hence the dispersion relation and the effective mass.

Therefore, we illustrate here a methodology applicable to individual semiconducting nanostructures for extracting effective masses of a two dimensional  $\sqrt{3}x\sqrt{3}$  Ga single atomic layer on Si(111) directly from scanning tunneling spectra. The methodology is based on calculating the tunnel current using its dependence on the effective density of states mass and a parabolic band approximation followed by fitting to the measured tunneling spectra. An effective mass of  $m_{\rm eff,C}=0.59 \pm 0.06$  is obtained for the empty surface state, in good agreement with a band structure calculation and inverse photo electron spectroscopy data.

## 6:40pm TF+NM-MoE4 α',α"-Fe<sub>16</sub>N<sub>2</sub> Interstitial Compound as a New Candidate for Rare Earth Free Permanent Magnet - From Thin Film to Bulk -, *M. Takahashi, Masahiro Tobise*, Tohoku University, Japan INVITED

After surprising first report ( $\alpha$ "-Fe<sub>16</sub>N<sub>2</sub> phase exhibited a giant saturation magnetization in 1972 as a thin film form [1]), many researches challenged to realize single phase  $\alpha$ "-Fe<sub>16</sub>N<sub>2</sub>. At 1993, present author et al. established the method in thin film to attain a relatively high volume fraction of a"- $Fe_{16}N_2$  using a reactive sputtering [2]. Precisely determined value of  $M_s$  of  $\simeq$ 240 emu/g ( $\simeq$ 2.2 T) even though relatively small value compared to initially reported one and value of  $K_u$  ( $\simeq 10^7$  erg/cm<sup>3</sup>) are very attractive as rare earth free permanent magnet material [3]. But as it was very difficult to form metastable  $\alpha$ "-Fe<sub>16</sub>N<sub>2</sub> single phase even in the thin film, it had been believed that the synthesis of a single phase  $\alpha"\text{-}\text{Fe}_{16}N_2$  in bulk form was almost impossible. In 2013, our group established the synthesis procedure of single-phase  $\alpha$ "-Fe<sub>16</sub>N<sub>2</sub> nanoparticle for the first time, and reported  $\alpha$ "-Fe<sub>16</sub>N<sub>2</sub> exhibit  $M_s$  of  $\simeq 234$  emu/g and  $K_u$  of  $\simeq 10^7$  erg/cm<sup>3</sup> [4]. This nanoparticle powder could be synthesized starting from the reduction of Feoxides and following nitriding with ammonia gas at temperatures around 145 °C under the very low moisture and oxygen contents less than 1 ppm through the all process. Mössbauer spectra also revealed that the perfect formation of the single phase  $\alpha"$  -Fe $_{16}N_2.$  In order to improve coercivity through the evaluation of magnetic interaction and the quality of  $\alpha$ " -Fe<sub>16</sub>N<sub>2</sub> crystalline, the anisotropy field  $H_k^{ptc}$  and switching field  $H_p$  are determined by rotational hysteresis loss analysis using randomly oriented nanoparticles assembly. Coercivity of nanoparticle assembly consisting of single-phase a"-Fe16N2 formed around 145 °C exceeds 2000 Oe. Normalized coercive force  $H_c/H_k^{ptc}$  and normalized switching field  $H_p/H_k^{ptc}$  are about 0.16 and 0.3, respectively. Coercivityhas been improved by surface treatment and reached 3200 Oe at present. Detail on the relationship between these magnetic properties and reversal mechanism is discussed.

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T.Ogawa,Y.Ogata,R.Gallage,N.Kobayashi,N.Hayashi,Y.Kusano,S.Yamamo to,K.Kohara,M.Doi,M.Takano and M.Takahashi, Appl. Phys. Express, 6 (2013) 073007

7:40pm TF+NM-MoE7 Interfaces between Transferred, CVD-Grown Graphene and MoS<sub>2</sub> Probed with STM and ARPES, *H. Coy-Diaz*, Department of Physics, University of South Florida, Tampa, FL 33620, USA, *J. Avila*, *M.C. Asensio*, 2. Synchrotron Soleil, Orme des Merisiers - Saint Aubin, BP 48 - 91192 - GIF SUR YVETTE Cedex, France, *Matthias Batzill*, Department of Physics, University of South Florida, Tampa, FL 33620, USA

Heterostructures made of different van der Waals materials are of increasing interest because of potential applications in energy harvesting and combination of spin- and valley-tronics. However, the interface properties of these materials are not yet well characterized. One challenge for their characterization is the preparation of large-area high quality materials that enable employment of surface characterization techniques such as scanning probe microscopy and photoemission spectroscopy. Here we demonstrate the transfer of CVD-grown graphene to bulk MoS<sub>2</sub> substrates and report the first STM and ARPES studies of such a system. As expected for weakly interacting materials STM studies only exhibit a very weak moire-superstructure and (nano) ARPES measurements show that the Dirac cone of graphene is maintained. However, (nano) ARPES also shows the formation of band-gaps in the pi-band of graphene where the out-of-plane molecular orbitals of MoS<sub>2</sub> intersect with the electronic-states of graphene. This modification of the electronic structure of graphene in the

graphene/MoS<sub>2</sub> heterostructure is contrary to expectations of simple van-der Waals stacked materials. The high quality of the samples will enable further studies of the spin state of the graphene and MoS<sub>2</sub> substrate as well as enable preparation of other heterostructure materials and thus will give a detailed description of the interaction in these heterostructure systems.

# 8:00pm **TF+NM-MoE8** Universality of Seebeck Coefficients in Graphene/h-BN Nano-Composites, *Yosuke Ayako, A. Akaishi, J. Nakamura,* The University of Electro-Communications (UEC-Tokyo) and JST-CREST, Japan

Thermoelectric materials have attracted much attention because of their promising applications in power generation. Recently, we have shown that the superlattices consisting of zigzag graphene nanoribbons (GNRs) and BN nanoribbons (BNNRs) have giant Seebeck coefficients [1]. Such giant Seebeck coefficients of the superlattice models stem from the so-called pudding-mold band with a finite energy gap [2]. Although such types of superlattices have great fascination with thermoelectricity, the experimental synthesiss of these two-dimensional structures may be an extremely-challenging task.

In the present study, we suggest more easy-to-make, practical onedimensional structures possessing the pudding-mold band. We propose the graphene/h-BN hybrid nanoribbons with zigzag edges (hereafter referred to as "nano-composites"), in which both edges of GNRs are terminated with BNNRs. In this study, we specify the models using integer n and m, which are the numbers of dimer lines of GNRs and BNNRs, respectively. The Seebeck coefficients of nano-composites have been evaluated on the basis of the Bolzmann transport theory. Electronic band structures have been calculated using the first-principles calculations within the framework of the density functional theory. We have also employed the armchair nanocomposites for comparison.

We have shown that the pudding-mold bands have been confirmed for the zigzag nano-composites, but not for the armchair ones. The Seebeck coefficients for the zigzag nano-composites decrease monotonically with increasing n. Their maximum values become higher than those for graphene and GNRs, though not to the extent of the superlattices [1]. On the other hand, the Seebeck coefficients for the armchair nano-composites do not become higher compared with those for the pristine armchair GNRs, since the mechanism of the enhancement based on the pudding-mold band does not work for these composites. Here, we should not overlook that the Seebeck coefficients for the armchair nano-composites show the oscillatory-decreasing behavior with increasing n, and their dependence on n can be classified into three categories of 3n, 3n+1, and 3n+2, being analogous to the electronic structure of the zigzag carbon nanotubes [3]. Nevertheless, the Seebeck coefficients shows the universal dependence on the band gaps: the maximal, absolute Seebeck coefficient depends only on the bandgap irrespective of the structural category of nano-composites.

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8:20pm **TF+NM-MoE9** Reduction of Oxygen on Nitrogen-Doped Graphene, *Akihide Ichikawa*, *A. Akaishi, J. Nakamura*, The University of Electro-Communications (UEC-Tokyo) and JST-CREST, Japan

Recently, several groups have reported high oxygen reduction reaction (ORR) activities in nitrogen-doped carbon nanomaterials which are candidates of metal-free catalysts for ORR [1]. Lee *et al.* have successfully fabricated nitrogen-doped graphene with the high ORR activity in acid media [2]. It has been confirmed that local atomic configurations of dopants in nitrogen-doped graphene are classified into three functional groups (pyrrole-like, pyridine-like, and graphite-like configurations) [3]. However, the mechanism of the ORR on the nitrogen-doped graphene has not fully understood.

In this work, we examine the ORR on the nitrogen-doped graphene containing the graphite-like N in a basal plane using first-principles calculations. In general, the ORR occurs mainly two pathways: The two-electron pathway (2e<sup>°</sup>) that is reduced to hydrogen peroxide (H<sub>2</sub>O<sub>2</sub>), and the direct four-electron pathway (4e<sup>°</sup>) that reduces to water (H<sub>2</sub>O). Thermodynamic electrode potentials of each process at standard conditions are about 0.68V (2e<sup>°</sup>) and 1.23V (4e<sup>°</sup>), respectively. In case of the associative mechanism for the two- and four- electron reduction pathways, the electrocatalytic activity is governed by the stability of reaction intermediates like OOH<sup>\*</sup>, OH<sup>\*</sup>, and O<sup>\*</sup> (where "\*" refers to a surface site). Free energies of the reaction intermediates have been calculated based on the computational hydrogen electrode model suggested by Norskov *et al.* [4]. We have taken account of effects of electrode potential, Ph of a solution, a local electric field in double layer, and water environment.

We have constructed energy diagrams at several electrode potentials on the basis of the first-principles calculations. It has been shown that the 2e<sup>-</sup> and 4e<sup>-</sup> reduction processes proceed at potentials up to about 0.5V and 0.8V, respectively. This means that we can control the reduction pathway for the nitrogen-doped graphene with the graphite-like N. Proton-electron transfer to OOH\* (the 2e<sup>-</sup> pathway), and the formation of OOH\* (the 4e<sup>-</sup> pathway) are confirmed to be the rate-limiting steps, respectively. The effects of electric field and water environment will also be discussed in the presentation.

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